## WHAT IS CLAIMED IS:

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- 1. An *n*-type diamondoid material comprising an electron-donating heteroatom.
- 2. The *n*-type diamondoid material of claim 1, wherein the electron-donating heteroatom is a group V element.
- 3. The *n*-type diamondoid material of claim 1, wherein the electron-donating heteroatom is selected from the group consisting of nitrogen, phosphorus, and arsenic.
  - 4. The *n*-type diamondoid material of claim 1, wherein the material comprises an aza-diamondoid.
- 15 5. The *n*-type diamondoid material of claim 1, wherein the electron-donating heteroatom occupies a substitutional site on the diamond lattice.
  - 6. The n-type diamondoid material of claim 1, wherein the electron-donating heteroatom is  $sp^3$ -hybridized in the diamond lattice.
  - 7. The *n*-type diamondoid material of claim 1, wherein the diamondoid is selected from the group consisting of adamantane, diamantane, and triamantane.
- 8. The *n*-type diamondoid material of claim 1, wherein the diamondoid is selected from the group consisting of tetramantane, pentamantane, hexamantane, heptamantane, octamantane, nonamantane, decamantane, and undecamantane.
  - 9. The *n*-type diamondoid material of claim 1, wherein the material is a polymerized heterodiamondoid.
  - 10. The polymerized heterodiamondoid material of claim 9, further including a metal atom to enhance electrical conductivity.

- 11. The polymerized heterodiamondoid material of claim 10, wherein the metal is gold.
- 5 12. A p-type diamondoid material comprising an electron-withdrawing heteroatom.
  - 13. The *p*-type diamondoid material of claim 12, wherein the electron-withdrawing heteroatom is a group III element.
- 10 14. The *p*-type diamondoid material of claim 12, wherein the electron-withdrawing heteroatom is selected from the group consisting of boron and aluminum.
  - 15. The *p*-type diamondoid material of claim 12, wherein the material comprises an boro-diamondoid.

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- 16. The *p*-type diamondoid material of claim 12, wherein the electron withdrawing heteroatom occupies a substitutional site on the diamond lattice.
- 17. The *p*-type diamondoid material of claim 12, wherein the electron withdrawing 20 heteroatom is sp<sup>3</sup>-hybridized in the diamond lattice.
  - 18. The p-type diamondoid material of claim 12, wherein the diamondoid is selected from the group consisting of adamantane, diamantane, and triamantane.
- 25 19. The *p*-type diamondoid material of claim 12, wherein the diamondoid is selected from the group consisting of tetramantane, pentamantane, hexamantane, heptamantane, octamantane, nonamantane, decamantane, and undecamantane.
- 20. The *p*-type diamondoid material of claim 12, wherein the material is a polymerized heterodiamondoid.

- 21. The polymerized heterodiamondoid material of claim 20, further including a metal atom to enhance electrical conductivity.
- 22. The polymerized heterodiamondoid material of claim 21, wherein the metal is 5 gold.
  - 23. An electrical p-n junction comprising a p-type diamondoid material and an n-type diamondoid material.
- 10 24. The *p-n* junction of claim 23, wherein the *n*-type diamondoid material is azaheterodiamondoid.
  - 25. The p-n junction of claim 23, wherein the n-type diamondoid material is phospho-heterodiamondoid.

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26. The *p-n* junction of claim 23, wherein the *p*-type diamondoid material is boroheterodiamondoid.

- 27. A diamondoid transistor comprising an *n*-type heterodiamondoid material and a p-type diamondoid material.
  - 28. The diamondoid transistor of claim 27, wherein the transistor comprises an n-p-n field effect transistor.
- 25 29. The diamondoid transistor of claim 27, wherein the transistor comprises an *p-n-p* field effect transistor.
  - 30. The diamondoid transistor of claim 27, wherein the *n*-type diamondoid material is aza-heterodiamondoid.
  - 31. The diamondoid transistor of claim 27, wherein the *n*-type diamondoid material is phospho-heterodiamondoid.

- 32. The diamondoid transistor of claim 27, wherein the *p*-type diamondoid material is boro-heterodiamondoid.
- 5 33. The diamondoid transistor of claim 27 further comprising a source, gate, and drain, wherein the source and drain are frabricated from the *n*-type heterodiamondoid material, and the gate is fabricated from the *p*-type diamondoid material.

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- 34. The diamondoid transistor of claim 27 further comprising a source, gate, and drain, wherein the source and drain are frabricated from the *p*-type heterodiamondoid material, and the gate is fabricated from the *n*-type diamondoid material.
  - 35. A method of synthesizing an *n*-type diamondoid material, the method comprising:
    - a) photo-oxidizing a diamondoid to form a hydroxy-diamondoid;
    - b) chemically oxidizing a diamondoid to a keto-diamondoid;
    - c) reducing the keto-diamondoid to a hydroxy-diamondoid;
    - d) preparing an aza-diamondoid-ene from the hydroxy-diamondoid;
    - e) preparing an epoxy aza-diamondoid from the aza-diamondoid-ene;
- 20 f) preparing an aza-diamondoid from the aza-diamondoid-ene.
  - 36. A method of synthesizing an n-type diamondoid material, the method comprising:
    - a) chemically oxidizing a diamondoid to a keto-diamondoid;
  - b) preparing a fragmented diamondoid carboxylic acid from the ketodiamondoid;
  - c) preparing a fragmented diamondoid-ene acetate from the fragmented diamondoid carboxylic acid;
- d) preparing a fragmented hydroxy-diamondoid-ene by reducing the fragmented diamondoid-ene acetate;
  - e) preparing a fragmented keto-diamondoid-ene by oxidizing the fragmented hydroxy-diamondoid-ene;

- f) preparing a fragmented diamondoid=N-OH-ene from the fragmented ketodiamondoid-ene;
  - g) preparing an aza-diamondoid from the fragmented diamondoid=N-OH-ene.
- 5 37. A method of preparing an n-type diamondoid material, the method comprising:
  - a) isolating a diamondoid from a petroleum feedstock using a distillation, heat treatment, and separation technique;
  - b) converting the diamondoid into a heterodiamondoid by substitutionally positioning an electron donating heteroatom on a diamond crystal lattice position.

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- 38. A method of preparing an p-type diamondoid material, the method comprising:
- a) isolating a diamondoid from a petroleum feedstock using a distillation, heat treatment, and separation technique;
- b) converting the diamondoid into a heterodiamondoid by substitutionally positioning an electron withdrawing heteroatom on a diamond crystal lattice position.
- 39. A diamondoid transistor comprising a substantially single material, the transistor comprising electrically conducting regions and electrically insulating regions, wherein:

the electrically conducting regions of the transistor comprise n and p-type heterodiamondoid materials; and

the electrically insulating regions of the transistor comprise undoped diamondoid materials.

- 40. The transistor of claim 39, wherein the *n*-type diamondoid material comprises aza-heterodiamondoid.
  - 41. The transistor of claim 39, wherein the n-type diamondoid material comprises phospho-heterodiamondoid.
- 30 42. The transistor of claim 39, wherein the *p*-type diamondoid material comprises boro-heterodiamondoid.